

Electronic supplementary information (ESI)

Role of Carrier-Transfer in the Optical Nonlinearity of Graphene/Bi₂Te₃ Heterojunctions

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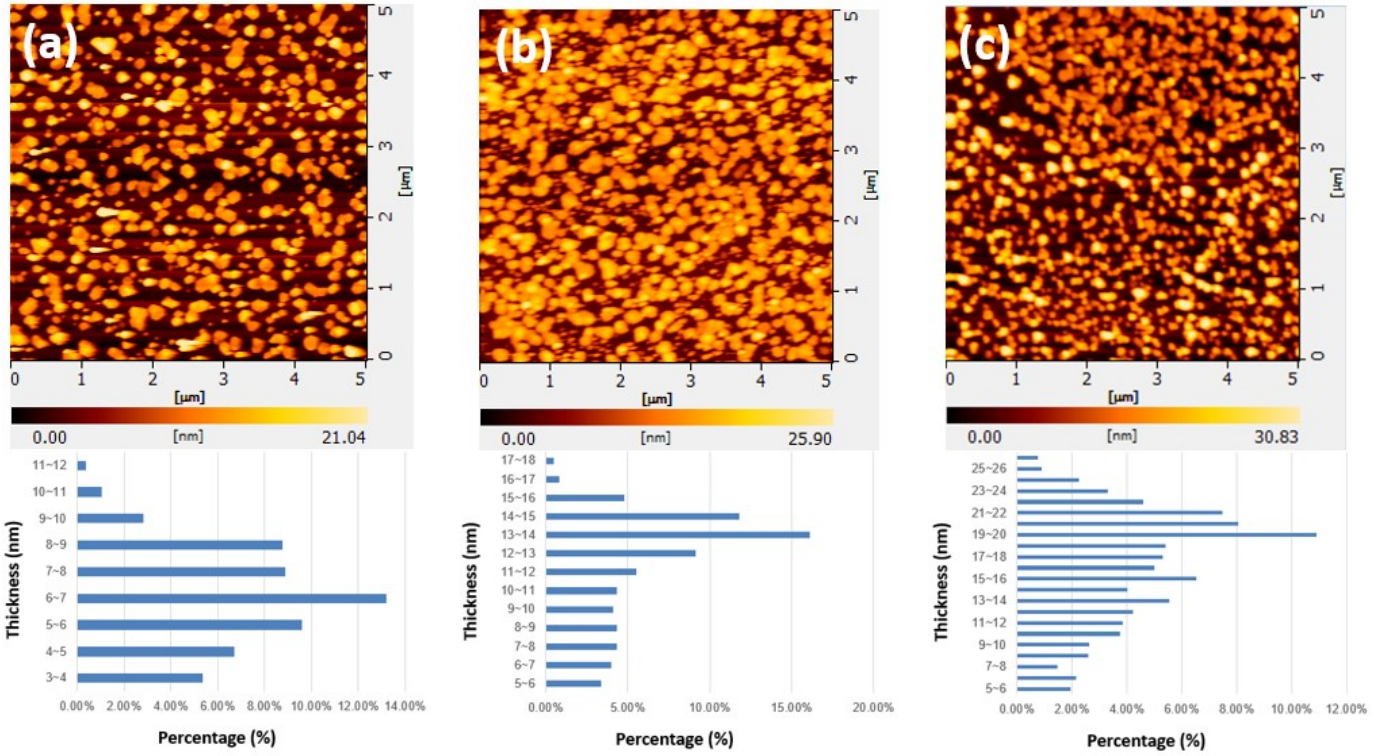


Fig. S1. AFM image and thickness distribution of (a) 6.5 nm, (b) 12.3 nm and (c) 16.5 nm Bi_2Te_3 nanoplates.

X-ray photoelectron spectrum (XPS) experiment was conducted by JEOL JAMP-9500F using Mg $\text{K}\alpha$ X-ray. Fig. S2 (a) is the wide range XPS of graphene/ Bi_2Te_3 heterojunction. Fig. S2 (b), (c)

and (d) are the deconvolution of C 1s, Bi 4f and Te 3d peak. In Fig. S2 (b), a peak is located at 284.03 eV, indicating the graphene C-C bonding. The Bi 4f_{7/2} spectrum is shown in Fig. S2 (c), there is one peak located at 158.73 eV, indicating the Bi₂Te₃ Bi-Te bonding. In Fig. S2 (d), beside the main peaks which located at 575.63 eV, the small components at 571.69 eV is stemming from surface oxidation which is commonly observed in synthesized topological insulator. Though there is little amount of oxidized state in Bi₂Te₃ nanoplate, they would not dramatically affect the Bi₂Te₃ electronic property. Similar results have been reported in previous study.¹ Therefore, one can conclude that a high-quality graphene/Bi₂Te₃ heterojunction with little oxidation was successfully fabricated.

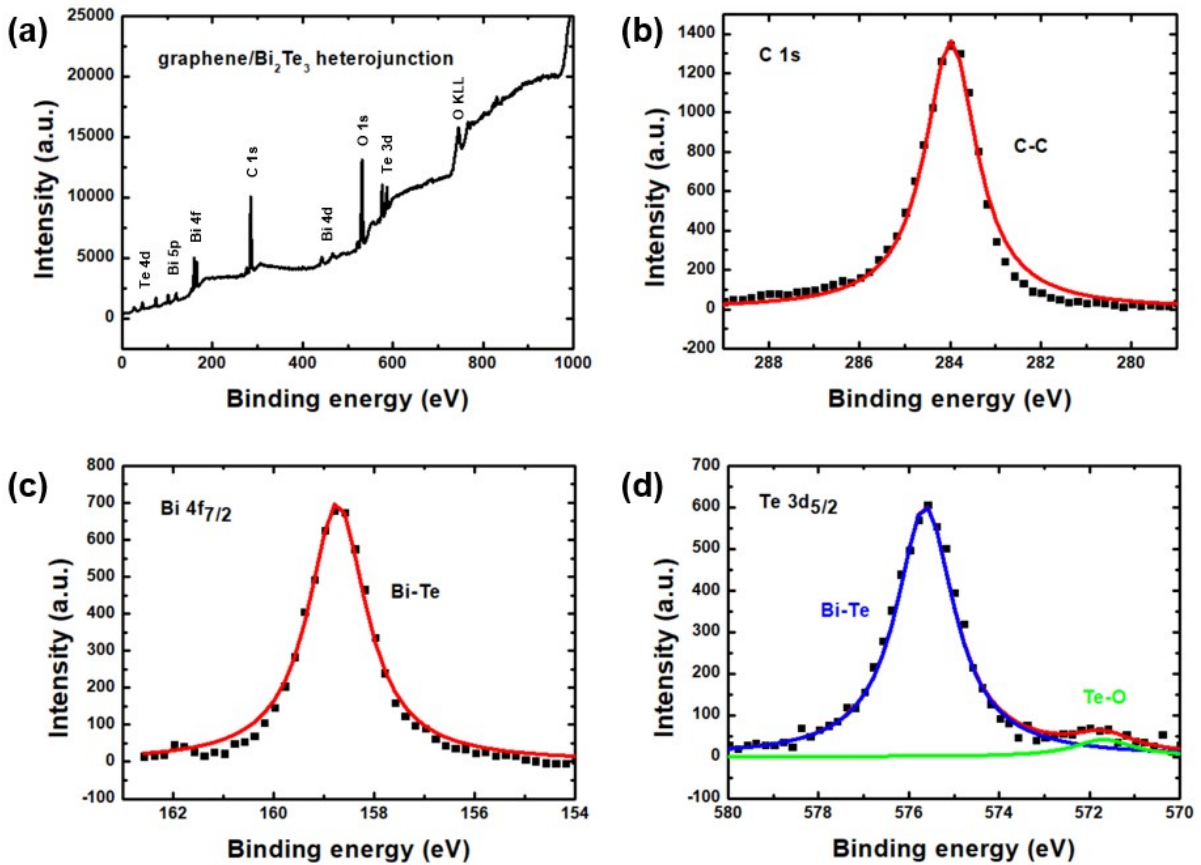


Fig. S2. (a) XPS for heterojunction of monolayer graphene with Bi_2Te_3 . (b) The C 1s peak, (c) the Bi 4f peak and (d) the Te 3d peak.

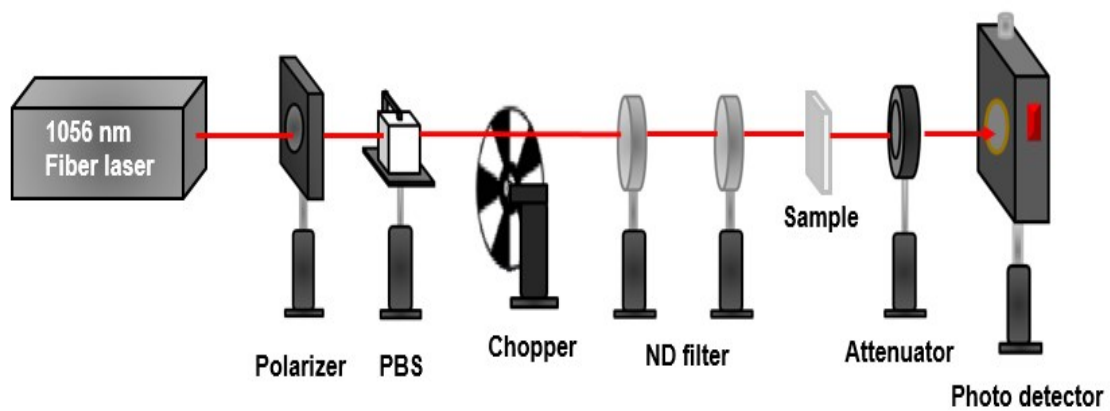


Fig. S3. Schematic of saturable absorption measurement.

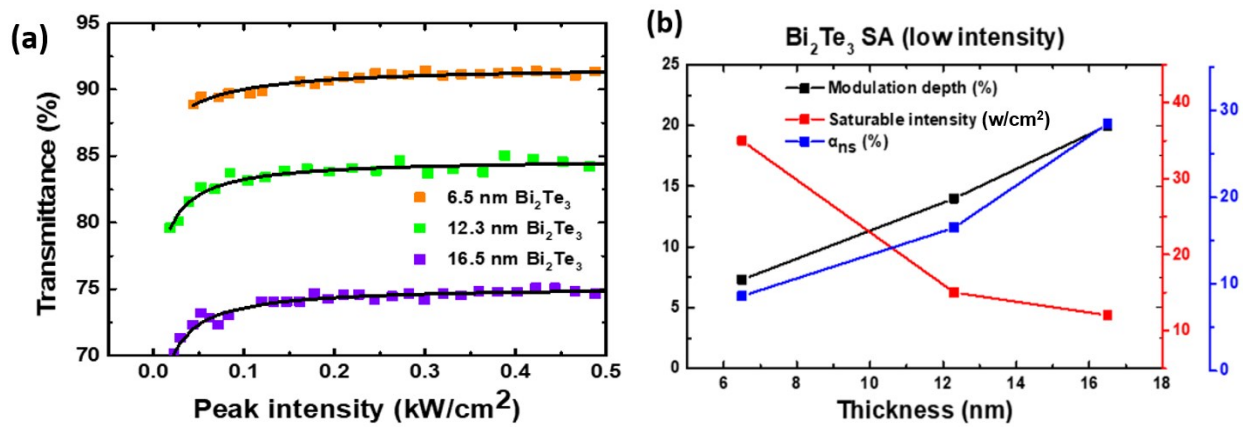


Fig. S4. (a) Nonlinear transmittances and fitting curves of 6.5 nm, 12.3 nm and 16.5 nm Bi₂Te₃ heterojunction at low optical intensity. (b) Fitting values of modulation depth, saturable intensity and non-saturable absorption coefficient at low intensity versus Bi₂Te₃ nanoplate thickness.

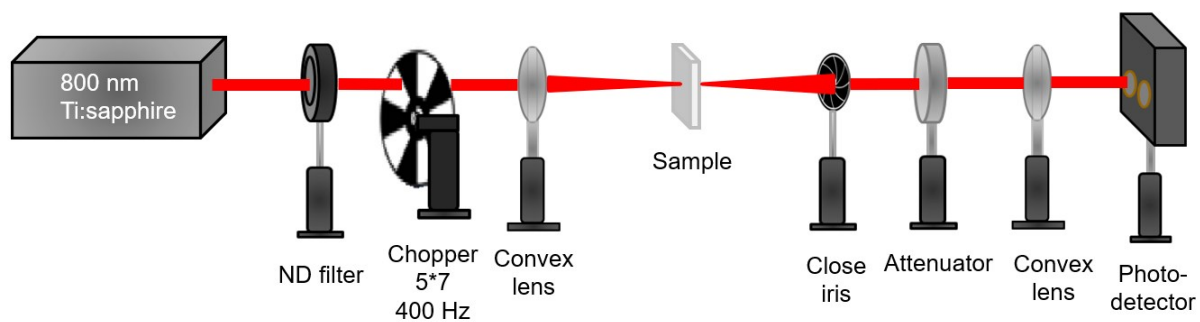


Fig. S5. Schematic of z-scan measurement.

The close aperture/open aperture data is fitted with conventional equation as bellow:

$$T_{CA/OA} = 1 + \frac{4 \times \frac{Z}{Z_R} \times \Delta\phi_0}{\left(\left(\frac{Z}{Z_R}\right)^2 + 1\right)\left(\left(\frac{Z}{Z_R}\right)^2 + 9\right)}$$

Where the Z is the sample position, $\Delta\phi_0$ is nonlinear phase shift, $Z_R = \pi\omega_0^2/\lambda$ is Rayleigh length, ω_0 is beam radius at focal point about $86.3 \mu\text{m}$, λ is laser wavelength. The $\Delta\phi_0$ of graphene/6.5 nm Bi_2Te_3 heterojunction under 98 MW/cm^2 is -0.028 . Finally, the nonlinear refractive index n_2 is:

$$n_2 = \frac{\Delta\phi_0}{I_0 \times k \times L}$$

Where the I_0 is peak intensity at focal point, k is wavenumber, L is sample thickness. The n_2 is then calculated about $-5.28 \times 10^{-9} \text{ cm}^2/\text{W}$.

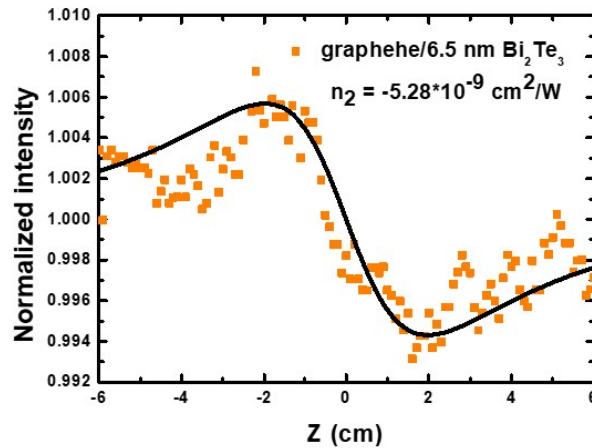


Fig. S6. Close aperture/open aperture z-scan result of graphene/6.5 nm Bi_2Te_3 under 98 MW/cm^2 .

Computation of graphene/Bi₂Te₃ heterojunction binding energy

Our first-principles calculations were performed via Vienna Ab-initio Simulation Package (VASP) to obtain the binding energy.^{2,3} Perdew-Burke-Ernzerhof (PBE) functional and the van der Waals D3 correction were employed to describe the exchange-correlation energy.^{4,5} We also considered the spin-orbit coupling in our calculation as Bi and Te atoms are heavy elements. In our calculation, we computed the adsorption energy within the heterojunction Bi₂Te₃ - graphene in mono-quintuple layer (QL) and two QLs of Bi₂Te₃. A 2×2×1 supercell of graphene with 8 carbon atoms was stacked above the QL of Bi₂Te₃, resulting in 10.88% strain for Bi₂Te₃. The optimized crystal structure is shown in Figure S4. The binding energy of the heterojunction graphene/mono-QL Bi₂Te₃ is -0.292 eV and the graphene/two-QLs Bi₂Te₃ is -0.278 eV.

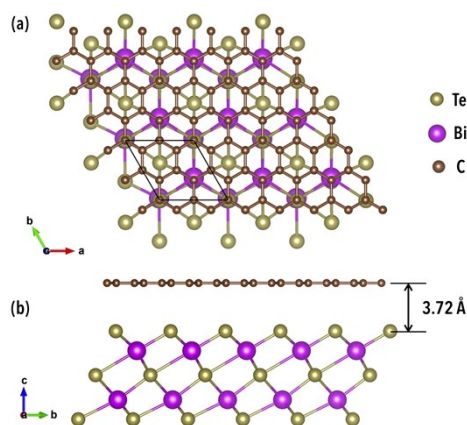


Fig. S7 (a) Top view and (b) side view of the equilibrium structure of mono-QL Bi₂Te₃ stacking with graphene.

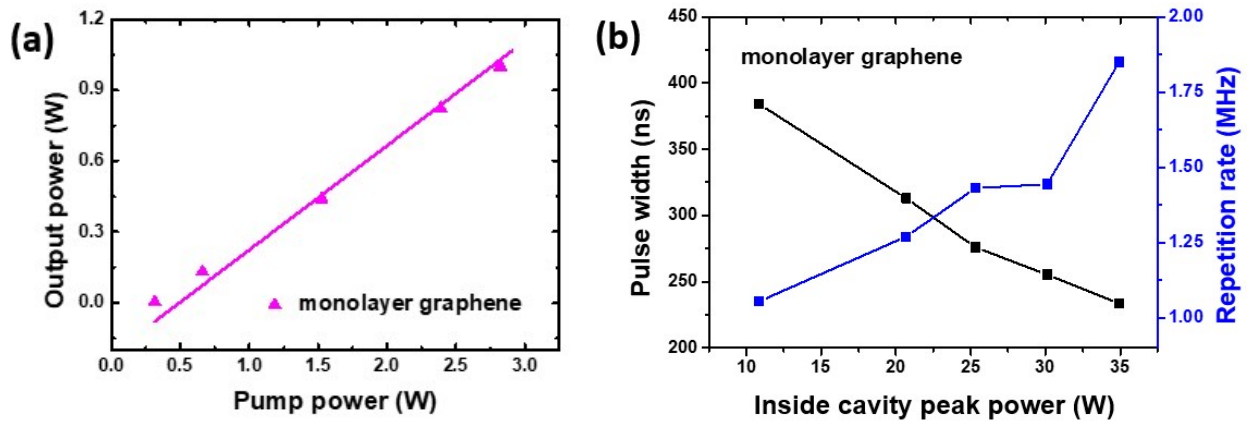


Fig. S8 (a) Average output power versus pump power of graphene. (b) Pulse width and repetition rate versus inside cavity peak power of graphene.

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